Special Issue

Development and Characterization of Nanocarriers for Drugs

Message from the Guest Editors

This Special Issue aims at providing cutting-edge studies focused on nanocarrier formulation design, analysis, and control of manufacturing processes, including those directed at the evaluation of critical parameters in the performance/quality of drug nanocarriers. Bearing in mind the growing advantage of applying multidisciplinary approaches to nanomedicine development, it is also envisioned to highlight important insights from simulations and modelling approaches, including those based on machine learning algorithms in alignment to Industry 4.0 assumptions, and regulatory requirements. It is our pleasure to invite you to submit a manuscript for this Special Issue. Full papers, communications, or timely reviews are all welcome.

Guest Editors

Dr. Carla Vitorino

Dr. Sandra Nunes

Dr. Tânia Cova

Deadline for manuscript submissions

closed (10 December 2021)



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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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